# **CVC 4 - Silicone Diffusion Pump Fluid**

Tetramethyltetraphenyl trisiloxane rich fluid for producing high vacuums in the range 10<sup>-8</sup> Torr. Exhibits excellent chemical, oxidation, thermal, hydrolysis and radiation resistance. Extremely low back streaming properties

#### **Features:**

- Good resistance to high temperature breakdown
- Ultra high vacuum performance
- Extremely low back streaming properties
- Rapid pump down
- Safer to use than hydrocarbon diffusion pump fluids

### Pack sizes:

500cc, 1 kg, 5 kg, 20 kg Further technical information is available upon request.

### **Applications:**

For particularly tough rugged applications requiring rapid pump down :-

- Vapour deposition of thin films by sputtering or evaporation, electron beam operations and high vacuum furnaces, melting, degassing and sintering, refractory metals and thick film deposition.
- Also suitable for all aspects of vacuum coating such as optics and automotive components
- UHV characteristics particularly useful for thin film, surface technology, thermonuclear and plasma physics applications







## **Typical characteristics:**

Specific Gravity gcm <sup>-3</sup> @ 25°C	1.07
Viscosity cSt @ 25°C	40 typical
Flash Point Open Cup°C	>210
Boiling Point (under vacuum) °C	230 typical
Ultimate Pressure Torr	10 <sup>-8</sup> - 10 <sup>-9</sup>



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